

10/538929

PATENT APPLICATION
JC17 REC 07 PCT/JP10 13 JUN 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q73500

Masahiro AMEMIYA, et al

Appln. No.: National Stage of PCT/JP2003/015792

Confirmation No.: Unknown

Group Art Unit: Unknown

Filed: June 13, 2005

Examiner: Unknown

For: CLEANING AGENT COMPOSITION, CLEANING AND PRODUCTION METHODS
FOR SEMICONDUCTOR WAFER, AND SEMICONDUCTOR WAFER

PRELIMINARY AMENDMENT

MAIL STOP AMENDMENT

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

Prior to examination, please amend the above-identified application as follows on the
accompanying pages.

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